

Photocatalytic mechanisms reactions of gallium doped TiO₂ thin films synthesized by sol gel (spin coating) in the degradation of methylene blue (MB) dye under sunlight irradiation

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Abstract

Thin films of pure TiO₂ and Ti_{1-x}Ga_xO₂ were prepared by the sol–gel method. The photocatalytic activity is tested by the degradation of the methylene blue (MB) dye under solar irradiation. Different methods are used in the characterization of materials and are X-ray diffraction, UV–visible. The results obtained show that the Ti_{1-x}Ga_xO₂ samples exhibit an anatase phase. The grain size has decreased. The degradation of methylene blue indicates that the photocatalytic activity of Ti_{1-x}Ga_xO₂ was significantly higher than that of pure TiO₂. The indication of photocatalytic efficiency could be effectively improved by gallium doping. The increase of oxygen vacancy amount and the realignment of the band gap resulting in the effect of Ga may be responsible for the enhancement of the photocatalytic activity. It found that the optimal photodegradation rate of 94% at t=180 min at the doping concentration is 4%.

Keywords Thin films \cdot Ti_{1-x}Ga_xO₂ \cdot Sol Gel (spin coating) \cdot Photocatalytic activity \cdot Sunlight \cdot Environmental pollution

Introduction

Photocatalysis has become a new and important topic because it can completely degrade organic pollutants into harmless inorganic substances (such as CO_2 , H_2O , etc.) under moderate conditions [1–4]. TiO₂ photocatalyst has gained considerable

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interest [5–12]. Anatase TiO₂, which is treated promising, has been an attraction in the photocatalytic degradation of environmental pollutants TiO₂ is proved the most suitable photocatalysts for its non-toxicity [1]. While, anatase TiO₂ (Eg=3.2 eV) which is treated as WBG (a wide band gap) semiconductor can just be activated under ultraviolet (UV) irradiation (λo =387 nm), which occupies only about 5% of solar energy. So, they tried every effort to develop photocatalysts that need less energetic but more sufficiently visible light through band engineering of doping [4, 6].

The main objective of metal ions doping is band gap narrowing and shifting up valence band or shift down conduction band of intrinsic TiO_2 , which creates shallow intermediate band levels into the forbidden band through substituting Ti atoms by dopants in TiO₂ lattice. The intermediate band levels would act as recombination centers, which decrease electron-hole recombination. This various single metal ions have been widely studied to address the optical limitation of TiO₂ materials. Including transition metals such as V [13–16], Cr [17–21], Mn [22], Fe [23], Co [24], Ni [25], Cu [26], Zn [27], Zr [14], Mo, Ru, Rh, Ag [28, 29], Pt, rare earth metals, such as Ce, Pr, Sm, Eu, Gd and Er, other metals such as Mg, Sr, Ba, Ca and Pb. A great deal of theoretical and experimental works have been focused on doping TiO₂ with single metal ions, the exploitation of TiO₂ with doping still has a profound perspective because the chemical states of doping ions determined by the fabrication method play a crucial role in the doping effect [30].

By reducing the magnitude of the energy band gap, photons of lower energy can be absorbed by the material as well as affecting the recombination rate. Doping generally results in a mixture of doped and non-doped elements in the semiconductor. Important aspects to keep in mind when doping the semiconductor is that the ground state should be lower than the O_2/H_2O level and conduction band higher than the H_2/H_2O level to enhance the generation of hydroxyl radicals and thereby the photocatalytic activity. Modification of energy band gap should also allow the mobility of excited electrons and electron-holes across the TiO₂ surface to be able to reach active sites [30].

Gallium has been considered to improve photocatalytic conduct compared to undoped TiO_2 [1, 31–33]. Ga-doping will induce oxygen vacancies gaps and build deficiencies near the conductive band in TiO_2 , which function as electron traps and increase the isolation of electron–hole pairs created by photographs [1, 33, 34]. In addition, due to the estimated ionic radii of Ga^{3+} (62 pm) and Ti^{4+} (68 pm), it is trivial to dope Ga^{3+} at Ti^{4+} sites in TiO_2 lattice [1, 31–33]. The synthesis of $Ga-TiO_2$ thin film has been obtained by different techniques as per the peer-reviewed literature such as the sol–gel method [1, 31, 33]. A hydrothermal method [1, 31, 35], and laser pyrolysis [36–38].

In this paper, $Ti_{1-x}Ga_xO_2$ thin films with x=0.00, 0.02, 0.04, 0.08, and 0.10, respectively, were prepared by sol-gel (spin coating) method. The aim of this work is role of Ga^{3+} on the photocatalytic activity of TiO_2 was investigated to obtain a higher photodegradation rate.

Experimental details

Preparation of Ti_{1-x}Ga_xO₂ thin films

 $Ti_{1-x}Ga_xO_2$ thin films with x = 0.00, 0.02, 0.04, 0.08, and 0.10, respectively, have been successfully synthesized by a modified sol-gel (spin-coating) process using HOLMARC Spin Coater. Sol-Gel method is considered a facile process for the fabrication of high-quality thin films of metal oxide materials. Starting solution with a concentration of 0.2 M which was prepared by dissolving 0.604 ml of titanium tetra iso-prop-oxide (Ti $[OC-H (CH_3)_2]_4$) as the solution, 10 ml of ethanol (C₂H₅OH)which was used as a solvent, 0.207 ml of acetylacetone (CH₃CH) as a catalyst and gallium nitrate: Ga(NO₃)₃ as a source of gallium doping. The mass of gallium nitrate changes from 0.01 g to 0.05 g. This solution is a transparent yellowish color and slightly viscous. Where the ratio of Titan Tetra (IV) isopropoxide and acetylacetone is 1:1. Sodalime glass plates $(2.5 \times 2.5 \times 0.15 \text{ cm}^3)$ are used as the substrates, which it was chemically cleaned. The mixture was further stirred for 3 h by heating at a temperature of 50 C. The mixture solution was deposited on glass substrates using a spin coating system. Then, it was injected onto the center of the glass substrate at a rotation speed of 4000 rpm for 30 s. After 30 s, the deposited films were dried at 250 °C for 10 min in a furnace to evaporate the organic solvent. This step was repeated five times. Finally, TiO₂ films were annealed for 2 h at 500 °C in the furnace.

Photocatalytic decolorization of MB

The photocatalytic activities of the as-synthesized samples were evaluated by photo-decolorizing methyl blue (MB) aqueous solution with a concentration of 15 mg/l. In each experiment, 10 mL of the MB solution is taken. Followed by the addition of TiO_2 thin films. The MB solution and TiO_2 thin films were exposed to natural sunlight in Algeria's country. All experiments are investigated at the 9:00 am in the month of September for 4 h. The dye concentration was determined by taking the UV absorption spectra using Perkin Elmer Lambda 950 UV/VIS spectrophotometer, in the wavelength range of 290–1100 nm. The highest absorbance at 664 nm was recorded for MB.

Characterization methods

The synthesized structural and optical properties of the synthesized TiO₂ films were characterized by different techniques. The structure of the films was acquired by X-ray diffractometer (XRD) spectra(Model: Bruker D8) using Cu K_{α} radiation (λ =1.5418 Å) at the 20 range of 10°- 90°, with the steps of 0.02°. Besides, Perkin Elmer Lambda 950 UV/VIS spectrometer using to determine

the optical properties of deposited thin film (film thickness, transmittance, gap energy) ranging from 290 to 1100 nm.

Results and discussion

Structural characteristics

The XRD results of $Ti_{1-x}Ga_xO_2$ (x=0, 0.02, 0.04, 0.06, 0.08 and 0.10) thin films shows in Fig. 1. The XRD results confirmed that the Ga-doped TiO₂ exhibits the tetragonal crystal structure with a single anatase phase and are agreed with the standard [JCPDS 21–1271]. The diffraction peak is $2\theta = 25.36$ indicating preferential crystal growth along the plane (101) [39].

The crystallite size (D) of $Ti_{1-x}Ga_xO_2$ films was measured using Scherrer's formula [39]

$$D = \frac{0.9\lambda}{\beta \cos\theta} \tag{1}$$

Fig. 2 shows the change of the crystallite size as a function of the gallium doping concentration. The crystallite size increases from 17.77 nm to 19.75 nm at



Fig. 1 The XRD spectra of the $Ti_{1-x}Ga_xO_2$ thin films prepared by sol gel (spin coating) with x = 0, 0.02, 0.04, 0.06, 0.08 and 0.1 annealed at temperature of 500 °C for 2 h with C=0.2 mol/L



Fig. 2 Crystallite size (D) of $Ti_{1-x}Ga_xO_2$ thin films prepared by sol gel (spin coating) annealed at temperature of 500 °C for 2 h with C=0.2 mol/L with x=0, 0.02, 0.04, 0.06, 0.08 and 0.1

x = 0.04. After that, it decreases to 9.30 nm with increasing doping concentration. The increase of crystallite size indicates an improvement of crystalline state of $Ti_{1-x}Ga_xO_2$ ($0 \le x \le 0.04$) thin films. This is results of Ga^{3+} ions incorporation into Ti^{3+} interstitials sites of TiO_2 lattice. At higher doping (x > 0.04), the effect of interstitials is compensated by the effect of substitution (Ti^{4+}) by Ga^{+3}) which leads to the decrease of crystallite size [40].

The dislocation density (δ) is defined as the length of dislocation lines per unit volume of the crystal has been calculated by using the Williamson and Smallman [39]:

$$\delta = \frac{1}{D^2} \tag{2}$$

Film thickness d has been calculated by using the Swanepoel method [39]:

Table 1Structural parametersof $Ti_{1,x}Ga_xO_2$ thin films preparedby sol gel (spin coating)	Samples Ti _{1-x} Ga _x O ₂	20	D (nm)	$\delta \times 10^{16} (\text{line/m}^3)$	Thick- ness d (nm)
	$\mathbf{x} = 0$	25.40	17.77	5.62	547
	x = 0.02	25.31	18.57	5.38	540
	x = 0.04	25.36	19.75	5.06	505
	x = 0.06	25.28	14.04	7.12	529
	x = 0.08	25.33	13.85	7.22	598
	x = 0.1	25.27	9.30	10.6	600

$$\mathbf{d} = \frac{\lambda_1 \lambda_2}{2(\lambda_1 \mathbf{n}_2 - \lambda_2 \mathbf{n}_1)} \tag{3}$$

The crystallite size, dislocation density (δ) and the thickness shows in the Table 1.

Optical properties

The optical transmission spectra of $Ti_{1-x}Ga_xO_2$ thin films shows in Fig. 3. It can be seen, that the $Ti_{1-x}Ga_xO_2$ thin films have high transmittance at the samples of TiO_2 , $Ti_{0.98}Ga_{0.02}O_2$, $Ti_{0.96}Ga_{0.04}O_2$, and $Ti_{0.94}Ga_{0.06}O_2$, where it reached 86%. This indicates that these samples have a good crystalline state and are consistent with the results obtained from DRX spectra.

After that, the transmittance decreases at $Ti_{0.92}Ga_{0.08}O_2$ and $Ti_{0.9}Ga_{0.1}O_2$. Whereas a higher concentration of Ga doping leads to a lower transmittance due to the interaction between the light and Ga³⁺ ion. The appearance of interference fringe was observed in the samples TiO_2 , $Ti_{0.98}Ga_{0.02}O_2$, $Ti_{0.96}Ga_{0.04}O_2$, and $Ti_{0.94}Ga_{0.06}O_2$. This indicates that the surface of the samples is smooth. As for other samples, the interference fringe did not appear which indicates that the surface of the samples is rough.

At high energy, absorption results from electronic transitions between wide states of band-to-band. Tauc law [39] usually describes it:

$$(\alpha h\nu)^n = A\left(h\nu - \mathbf{E}_g\right) \tag{4}$$

Here hv is the photon energy, Eg is optical gap n and A are constants, n characterizes the optical type of transition and takes the values 2 for allowed direct transitions or 1/2 for allowed indirect transitions).



Fig. 3 The optical transmission spectra of $Ti_{1,x}Ga_xO_2$ thin films deposited by sol gel (spin coating) annealed at temperature of 500 °C for 2 h with C=0.2 mol/L; x=0, 0.02, 0.04, 0.06, 0.08 and 0.1



Fig.4 Direct band gap of $Ti_{1,x}Ga_xO_2$ thin film annealed at temperature of 500 °C for 2 h with C=0.2 mol/L with x=0, 0.02, 0.04, 0.06, 0.08 and 0.1

The direct band gab of $Ti_{1-x}Ga_xO_2$ film with different Ga doping concentrations shows in Fig. 4. It was observed that the direct band gab decreases with increasing the Ga doping concentration at the sample $Ti_{0.96}Ga_{0.04}O_2$ and then increasing with increasing Ga doping concentration at the samples $Ti_{0.92}Ga_{0.08}O_2$ and $Ti_{0.9}Ga_{0.1}O_2$. In addition, it was observed that the direct band gab of Ga doped TiO_2 films less than of the pure TiO_2 films. This can be explained by the doping of Ga^{3+} ions can form a Ga^{3+} dopant level above the valence band (VB) of TiO_2 . The indirect band gab of $Ti_{1-x}Ga_xO_2$ film with different Ga doping concentrations shows in Table 2.

Table 2Direct and indirectband gap of $Ti_{1-x}Ga_xO_2$ thinfilms prepared by sol gel (spincoating)	Samples Ti _{1-x} Ga _x O ₂	Direct band gab (eV)	Indirect band gab (eV)
	$\mathbf{x} = 0$	3.55	3
	x = 0.02	3.30	2.96
	x = 0.04	2.99	2.76
	x = 0.06	3.38	3.24
	x = 0.08	3.46	3.33
	x = 0.1	3.44	3.29

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Fig.5 a UV–Vis absorption spectra of MB solution. b UV–Vis absorption spectra of MB solution with $C_{MB}=15$ mg/L after reacting with $Ti_{1-x}Ga_xO_2$ thin films (x=0, 0.02, 0.04, 0.06, 0.08 and 0.1) for 4 h sunlight irradiation

Photocatalytic activity studies

Photocatalytic activity of Ti_{1-x}Ga_xO₂ films

Photocatalytic activity of $Ti_{1-x}Ga_xO_2$ films was evaluated by photodecomposition of MB dye in an aqueous solution of a concentration of $C_0=15$ mg/L as a model pollutant. Fig. 5b shows the absorption spectrum of MB solution catalyzed over thin films. It can be seen that the absorption intensity (A) of MB solutions containing Ga- doped thin films is less than that of non-doped. This indicates that the removal of MB dye solution is greater when using the activated slices, while it can be concluded that the Ga-doped TiO₂ thin films have an effective role in the effectiveness of photocatalysis.

The photocatalytic degradation rate (*PDR*) of thin films for the photocatalytic degradation of organic pollution dye solution was calculated with the formula [41].

$$PDR(\%) = \frac{A_0 - A_t}{A_0} \times 100$$
(4)

Here A_0 is the absorbance of MB dye solution before the illumination and A_t is the absorbance of MB dye after sunlight exposure time *t*.

The values of photodegradation rate variation of Ga doped concentration are shown in Fig. 6. After 4 h sunlight irradiation, about 95% of MB molecules are decolorized over the $Ti_{0.96}Ga_{0.04}O_2$ thin film, while only 84%, 89.2%, 92.2%, 91.2% and 87.3% are decolorized over TiO₂, $Ti_{0.98}Ga_{0.02}O_2$, $Ti_{0.94}Ga_{0.06}O_2$, $Ti_{0.92}Ga_{0.08}O_2$, and $Ti_{0.9}Ga_{0.1}O_2$ thin films respectively. It was clearly seen that the photodegration rate is increased with Ga-doping concentration, getting more efficient at $Ti_{0.96}Ga_{0.04}O_2$ and then decreased gradually due to at a higher concentration the



Fig. 6 Photocatalytic degradation rate of MB solution after reacting with $Ti_{1-x}Ga_xO_2$ thin films with x = 0, 0.02, 0.04, 0.06, 0.08 and 0.1 for 4 h sunlight irradiation

distance between trapping sites decreases and thus increases the probability of recombination rate of the charge carriers [20]. Lin et al. [21, 42] and Mathews et al. [43].

Mechanism of photocatalytic reaction

The possible mechanism for enhanced Photocatalytic activity of Ti_{1,v}Ga_vO₂ thin films is proposed as follows. Due to the Ga doping, the band edge shifted into the visible light, which would be favorable for the Photocatalytic activity under visible light. When the semiconductor $Ga-TiO_2$ doped thin films were exposed to suitable light, electrons (e -) are excited to the conductive band (CB) from the valance band (VB), which leads to generating electron $(e_{-})/(h_{+})$ hole pairs (Eq. 5) [43] The ionic radius of Ga³⁺ (0.62 Å) being slightly lesser than the ionic radii of the Ti⁴⁺ (0.68 Å) [17, 44, 45], it is possible for the Ga³⁺ to substitute and occupy Ti⁴⁺ sites. The DRX spectra found no significant difference of the 2θ on anatase plane (101) between pure TiO₂ and Ga-doped TiO₂ thin films, which also implies that Ga³⁺ can easily enter into the lattice of TiO_2 and substitute for the Ti^{4+} ion. As a result, the substitution of Ga³⁺ to Ti⁴⁺ ion could create a charge imbalance and then more H₂O/hydroxide ions would be adsorbed onto the surface of TiO₂ catalysts for charge balance. These adsorbed H₂O or OH-ions on the surface could trap the surface holes and produce highly reactive hydroxide radicals (OH). [46, 47] which could not only suppress the photo-induced electron-hole pair recombination rate, but also oxidize and adsorb more reactive substrates, and then improved its photocatalytic performance efficiently. The doped Ga³⁺ions reduce the photoinduced electron-hole pair recombination rate due to the energy level Ga^{3+}/Ga^{4+} . Photo-oxidation process (Eq. 6) above the VB of anatase TiO₂, develops charge carrier separation [43, 46]. The trapped surface holes in the photooxidation can migrate to the surface adsorbed hydroxyl ions to generate hydroxyl radicals (OH·) (Eq. 7).

$$\operatorname{Ti}_{1-x}\operatorname{Ga}_{x}\operatorname{O}_{2} + h\nu \to \operatorname{Ti}_{1-x}\operatorname{Ga}_{x}\operatorname{O}_{2} + \left(e_{CB}^{-} + h_{VB}^{+}\right)$$
(5)

$$Ga^{3+} + h_{VB}^+ \to Ga^{4+} \tag{6}$$

$$Ga^{4+} + OH^{-}(Ads) \rightarrow Ga^{3+} + OH^{-}$$

$$\tag{7}$$

 Ga^{3+} traps the photoinduced electron to form Ga^{2+} Eq. 8, and the trapped electrons transfer to the surface adsorbed O₂ (Eq. 9) or a neighboring Ti⁴⁺ ions, and thus yield superoxide radicals (O₂⁻⁻) [46, 47]. The energy level of Ga³⁺/Ga²⁺ below the CB of anatase TiO₂ [24], supporting to enhance the charge carrier separation and resulting in the decline of the (e-)/(h+) pair recombination. The subsequent reactions Eqs. 7 and 9 demonstrated that Ga³⁺ could act as electron-hole trapper [48, 49]. As a result, the doping of suitable Ga³⁺ ions is favorable for the decrease of the photo induced e -/h+ pairs recombination rate and favors the improvement of photocatalytic activity.

$$Ga^{3+} + e^-_{CB} \to Ga^{2+} \tag{8}$$

$$Ga^{2+} + O_2(ads) \rightarrow Ga^{3+} + O_2^{\cdot} \tag{9}$$

However, at very high doping concentration, unfortunately Ga^{3+} ions can performance as a charge carrier (photo induced electrons and holes) recombination centers (Eqs. 10 and 11), and due to decrease the distance between trapping sites at a high concentration of Ga^{3+} ions and resulting in decline of the Photocatalytic activity.

$$Ga^{4+} + e^-_{CB} \to Ga^{3+} \tag{10}$$

$$Ga^{2+} + h_{VB}^+ \to Ga^{3+}$$
(11)

Conclusion

Ti_{1-x}Ga_xO₂ thin films were prepared by sol-gel (spin coating). The influence of the gallium doping concentration on the properties of TiO₂ was studied. The obtained results confirmed that the Ga-doped TiO₂ exhibits the tetragonal crystal structure with a single anatase phase. The grain size varied from 9.3 nm to 19.75 nm. The direct optical bandgap varied between 2.99 eV and 3.55 eV. It found that the optimum photodegradation rate of 94% at t=180 min at doping concentration is 4%. It can be concluded, that the doping of galium ($0 \le x \le 0.04$) is narrowing the band

gap, which creates shallow intermediate band levels into the forbidden band through Ga^{3+} ions incorporation into Ti^{3+} interstitials sites of TiO_2 lattice. The intermediate band levels would decrease electron-hole recombination. The latter increase the photocatalytic activity.

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